



## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: N. HASEGAWA, et al.

Serial No.: 10/674,381

Filed: October 1, 2003

For: METHOD OF MANUFACTURING SEMICONDUCTOR

INTEGRATED CIRCUIT DEVICE OPTICAL MASK THEREFOR,

ITS MANUFACTURING METHOD, AND MASK BLANKS

Group: 1756

Sir:

Examiner: Saleha R. MOHAMEDULLA

requested extension of time is attached hereto.

## PETITION FOR EXTENSION OF TIME

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

July 19, 2005

In the matter of the above-identified application, Applicant hereby respectfully petitions for an extension of time to permit filing a response within the third month subsequent to expiration of the shortened statutory period set

in the outstanding Office Action mailed January 19, 2005. A credit card payment form in the amount of \$1020.00 to cover the required fee for the

It is respectfully requested that any shortage in the fee be charged to the account of Antonelli, Terry, Stout & Kraus, LLP, Account No. 01-2135 (501.39055CX1) and excess fees credited to account.

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Respectfully submitted,

William I. Solomon/

Registration No. 28,565

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